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Kinetics of Zr-Al intermetallic compound formation during ultra-high vacuum magnetron sputter-deposition of Zr/Al₂O₃(0001) thin films

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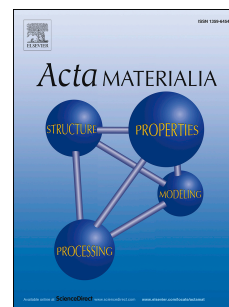
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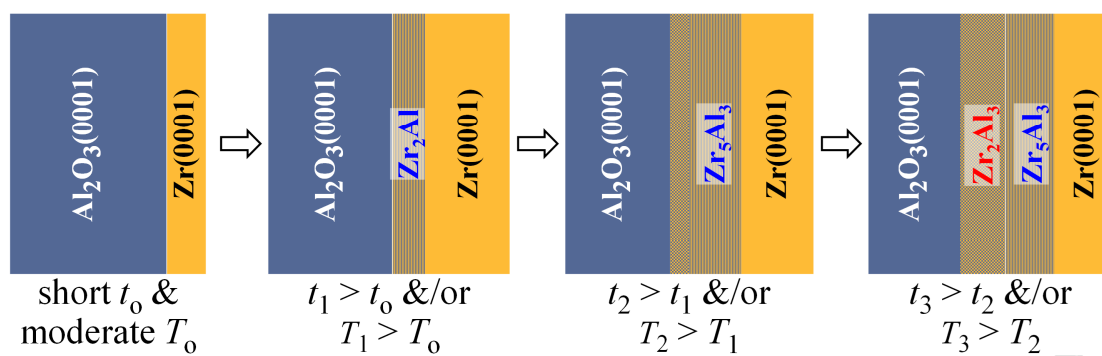
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